

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT	ATTY DOCKET NO.	SERIAL NO.
	SJ09-2000-0009US1	Unassigned 09/944,648
	APPLICANT	
	Dinan et al.	
	FILING DATE	GROUP
	August 31, 2001	Unassigned 2652

U. S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
Chu	AA	5,282,308	2/1994	Chen et al.	29	603.18	
	AB	5,285,340	2/1994	Ju et al.	360	119	
	AC	5,774,308	6/1998	Ohtsuka et al.	360	126	
	AD	5,805,391	9/1998	Chang et al.	360	113 317	
Chu	AE	6,043,960	3/2000	Chang et al.	360	126 317	
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	NAME	CLASS	SUBCLASS	TRANSLATION YES NO
Chu	AL	JP 57078613A	5/1982	Japan	Canon Inc			
Chu	AM	JP 01267812A	1/1989	Japan	TDK Corp			
Chu	AN	JP 03228210A	1/1991	Japan	Fujitsu Ltd			
	AO							
	AP							

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Chu	AQ		IBM Technical Disclosure Bulletin, Vol. 40 No. 04, April 1997, entitled: Sidewall Formation Using Silicon Nitride Mask for Horizontal/Planar Magnetic Heads
	AR		IBM Technical Disclosure Bulletin, Vol 40 No. 04, April 1997, entitled: Sidewall Process for Horizontal/Planar Magnetic Heads
	AS		

EXAMINER	DATE CONSIDERED
Chu Tunge	05/02/03
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	